

# Synchrotron Radiation Results

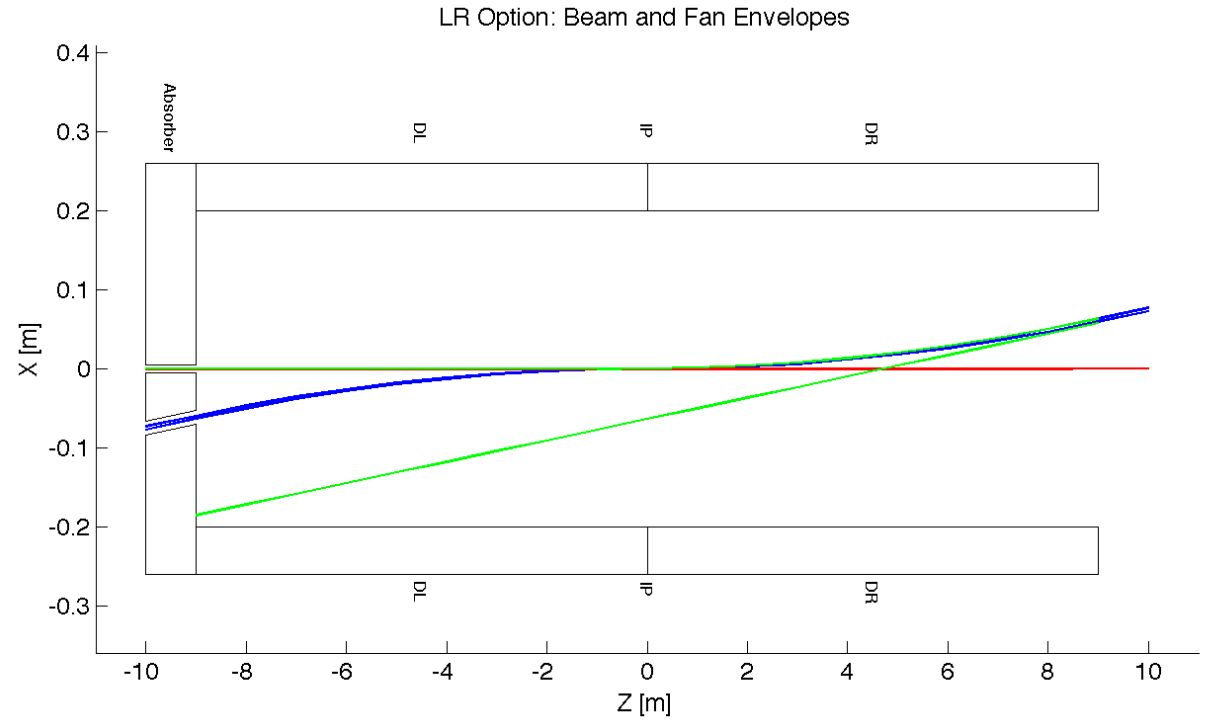


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# LR Option

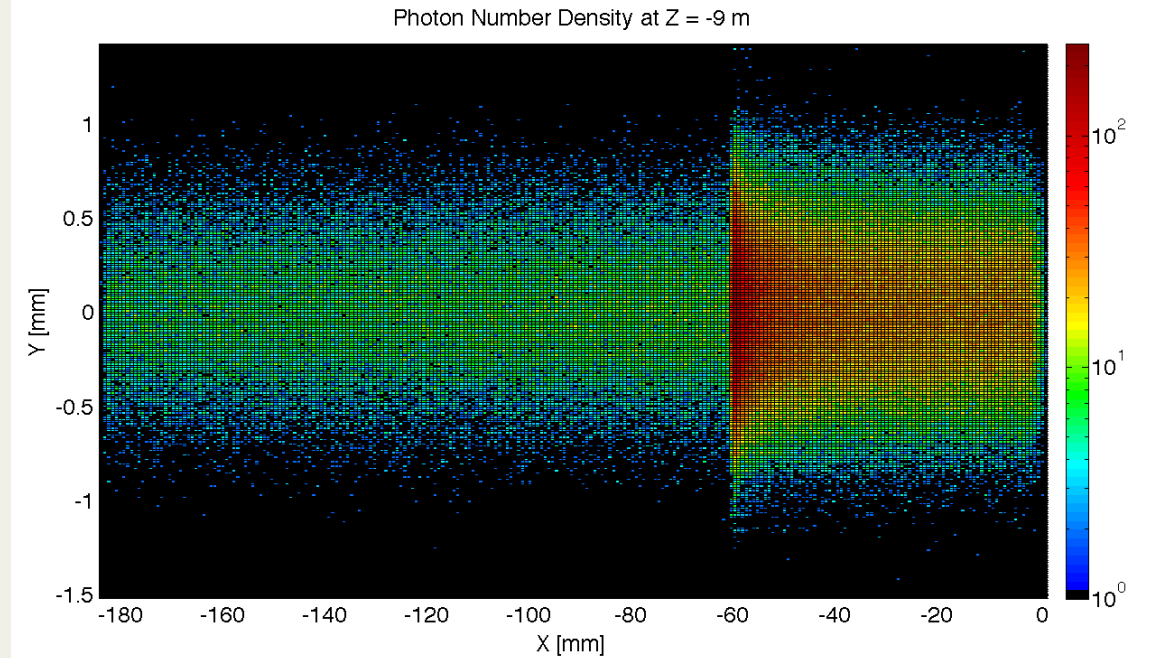
Element	Power [kW]	Critical Energy [keV]
DL	24.1	718
DR	24.1	718
Total/Avg	48.2	718

Table 4.2: LR: Power and Critical Energies [Geant4]

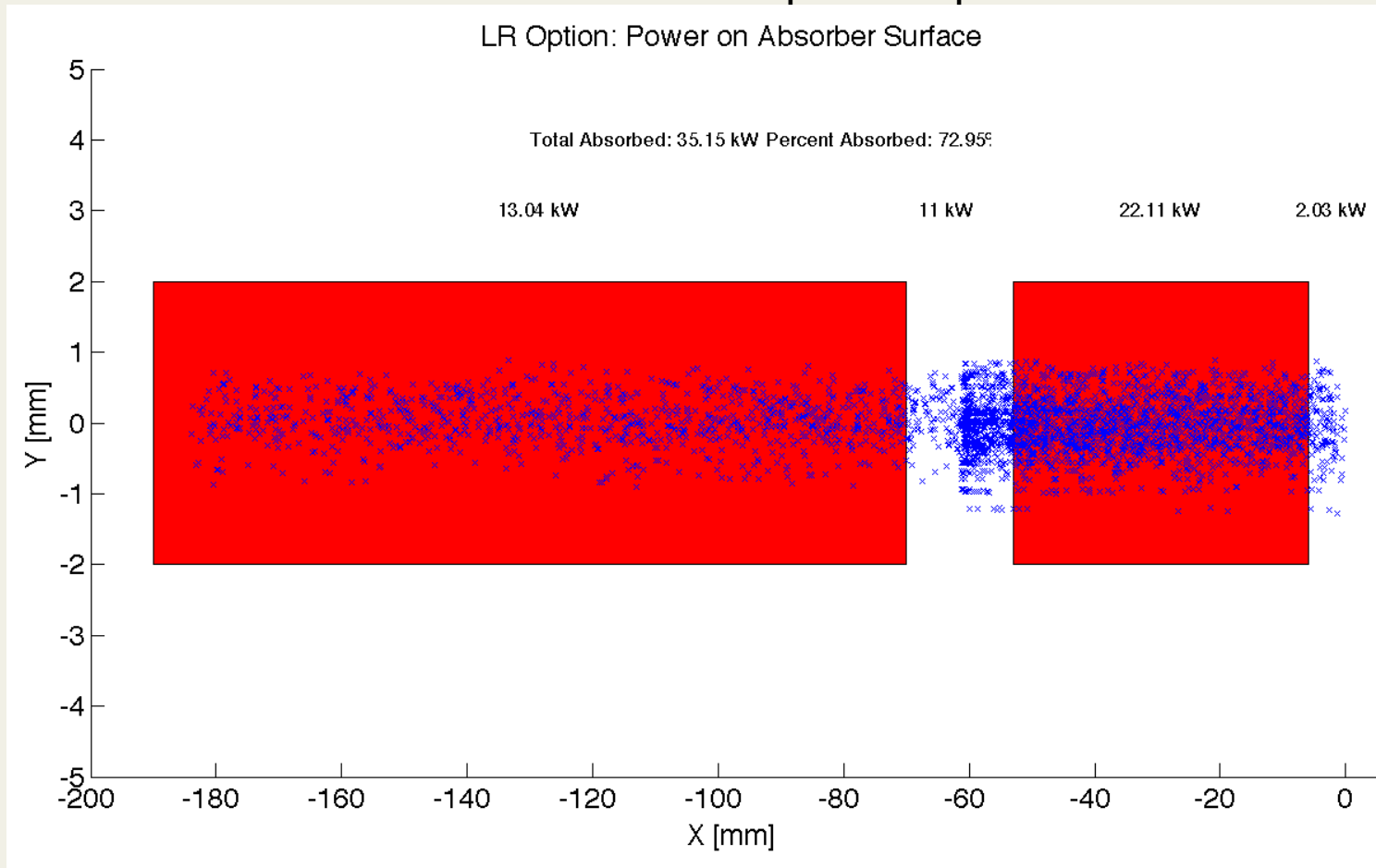


Characteristic	Value
E [GeV]	60
I [mA]	6.6
$\theta_c$ [mrad]	0
Abs. Pos. [m]	-9
B [T]	0.3
Separation [mm]	61.4
$\gamma/s$	$1.37 \times 10^{18}$

Table 4.1: LR: Parameters



- 35.15 kW or 72.95% will hit the absorber surface.
- 11 kW will continue in the electron aperture.
- 2.03 kW will continue in the proton aperture.



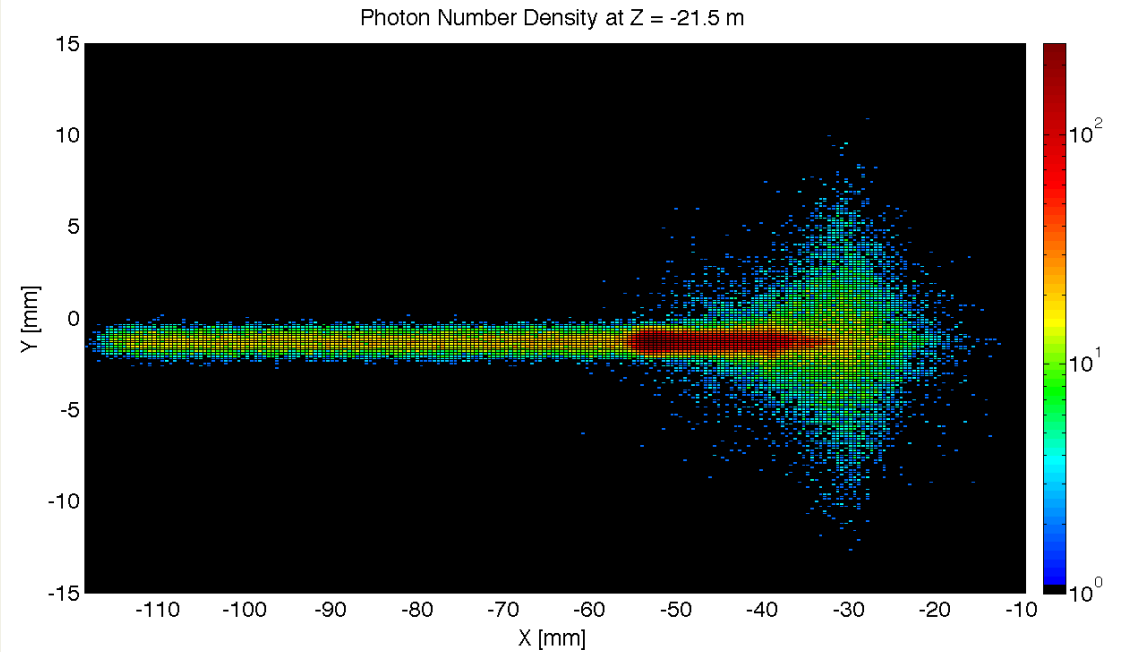
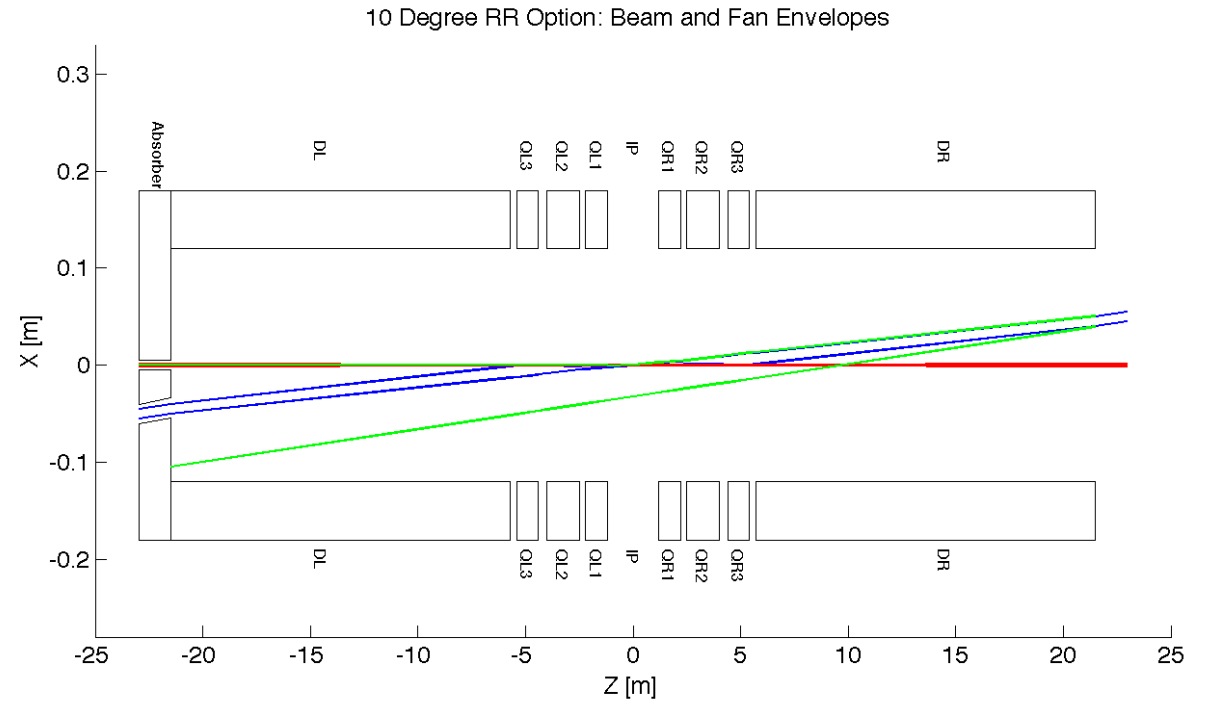
# RR 10 Degree

Element	Power [kW]	Critical Energy [keV]
DL	6.4	71
QL3	5.3	308
QL2	4.3	218
QL1	0.6	95
QR1	0.6	95
QR2	4.4	220
QR3	5.2	310
DR	6.4	71
Total/Avg	33.2	126

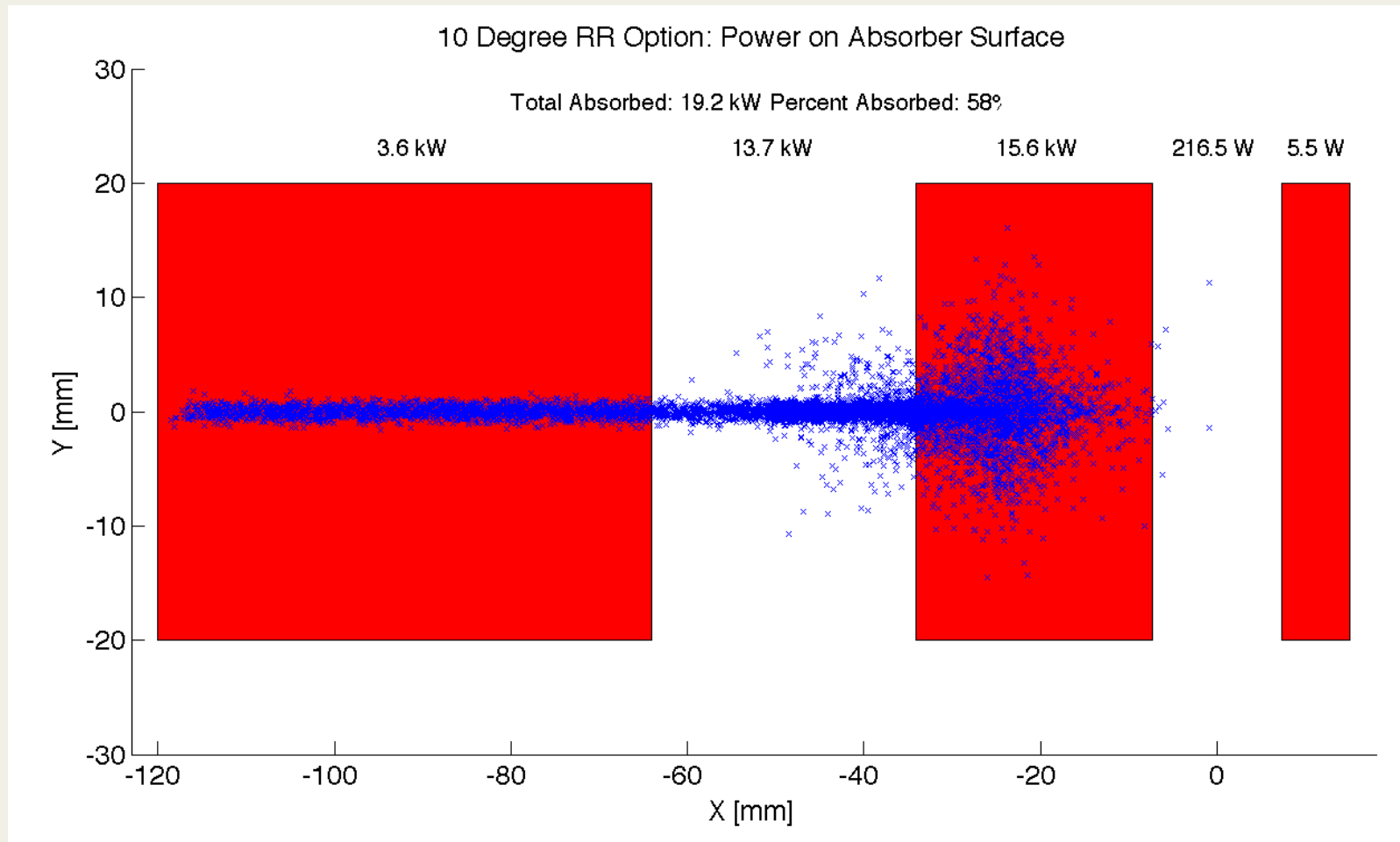
Table 3.2: 10 Degree: Power and Critical Energies [Geant4]

Characteristic	Value
E [GeV]	60
I [mA]	100
$\theta_c$ [mrad]	1
Abs. Pos. [m]	-21.5
B [T]	0.0296
Separation [mm]	55.07
$\gamma/s$	$5.39 \times 10^{18}$

Table 3.1: 10 Degree: Parameters



- 19.2 kW or 58% will hit the absorber surface.
- 13.7 kW will continue in the electron aperture.
- 216.5 W will continue in the proton aperture.



# RR 1 Degree

Element	Power [kW]	Critical Energy [keV]
DL	13.9	118
QL2	6.2	318
QL1	5.4	294
QR1	5.4	293
QR2	6.3	318
DR	13.9	118
Total/Avg	51.1	163

1 Degree RR Option: Beam and Fan Envelopes

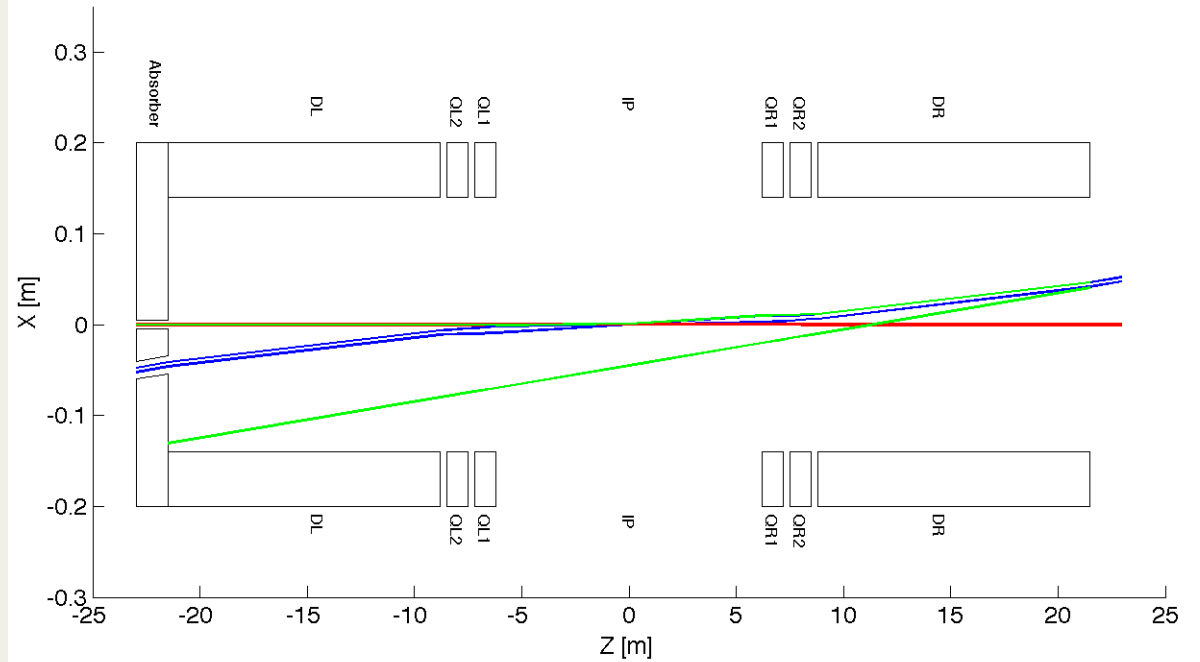
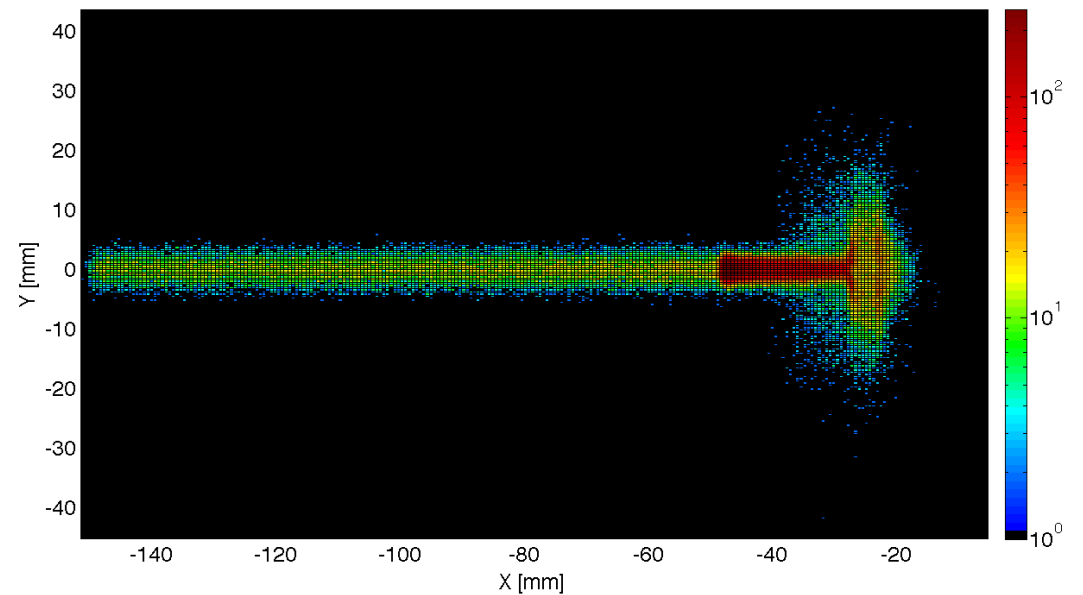


Table 3.6: 1 Degree: Power and Critical Energies [Geant4]

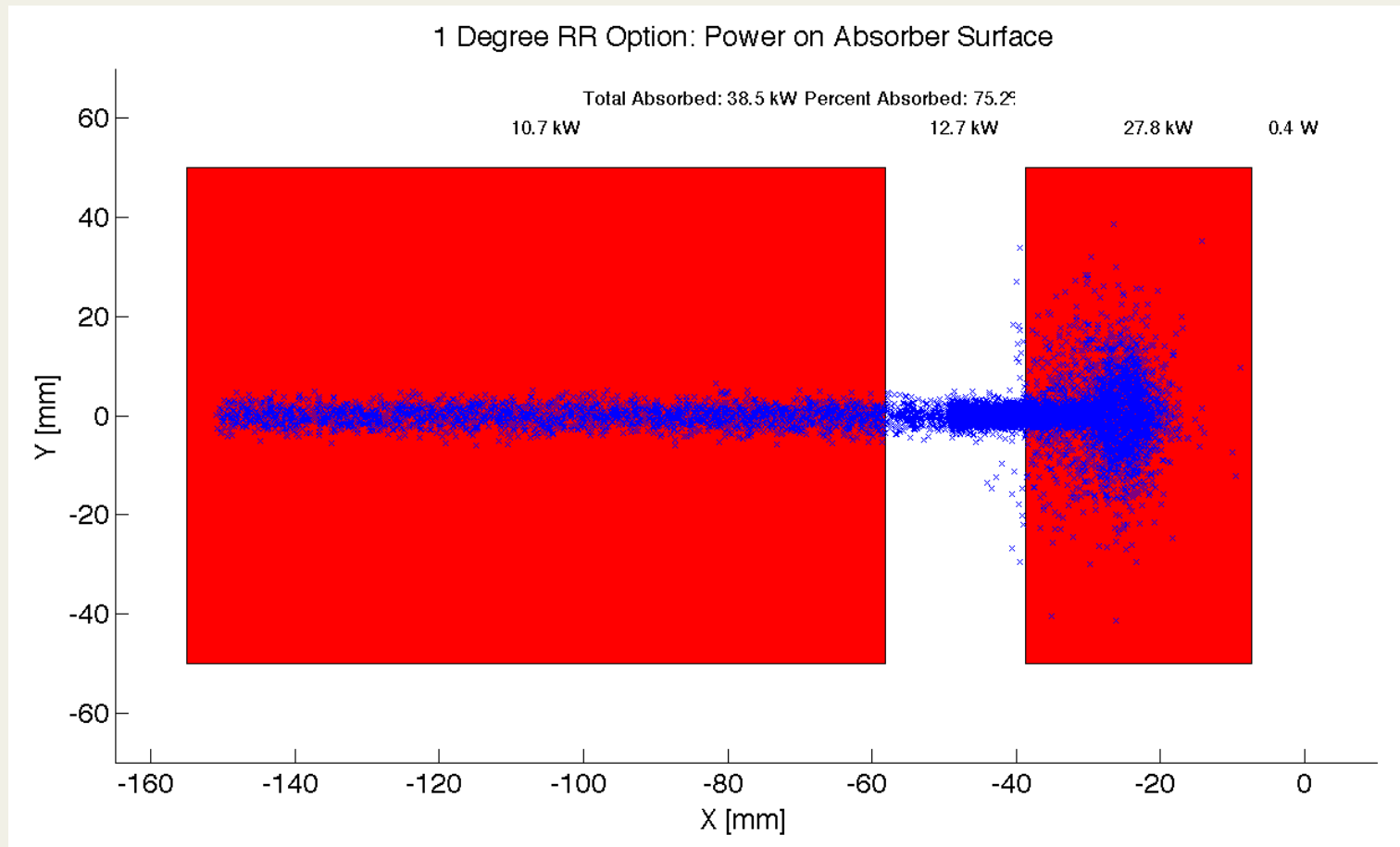
Characteristic	Value
E [GeV]	60
I [mA]	100
$\theta_c$ [mrad]	1
Abs. Pos. [m]	-21.5
B [T]	0.0493
Separation [mm]	55.16
$\gamma/s$	$6.41 \times 10^{18}$

Table 3.5: 1 Degree: Parameters

Photon Number Density at Z = -21.5 m



- 38.5 kW or 75.2% will hit the absorber surface.
- 12.7 kW will continue in the electron aperture.
- 0.4 W will continue in the proton aperture.



# Cross Check

- Below the results for Geant and the analytic method are compared for radiated SR power.
- This is a test of the analytic method for the quadrupole, hence the quadrupole offsets are left out.

Element	Power [W]	
	Analytic	Geant4
Q1	4226	4231.8 +/- 92.7
Q2	5153.5	5173.7 +/- 91.5
Total	9379.5	9405.5 +/- 130.3

TABLE VI: High Acceptance Comparison

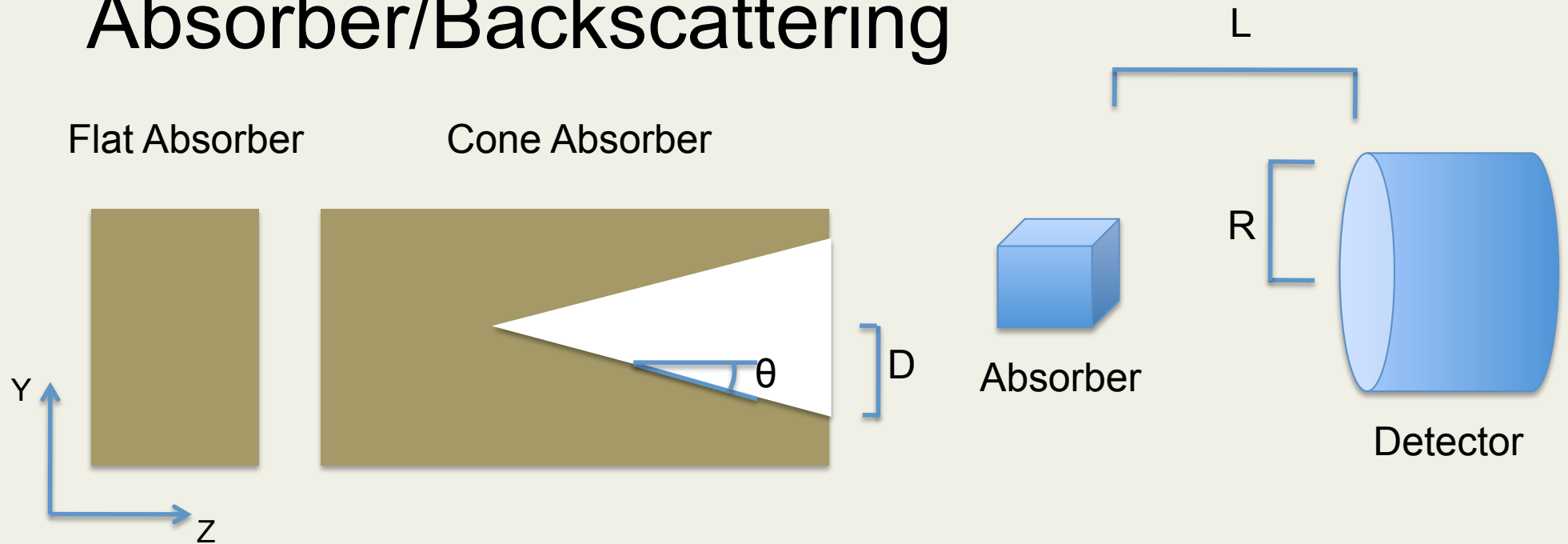
Element	Power [W]	
	Analytic	Geant4
Q1	212.5	210.9 +/- 9.2
Q2	3984	3943.2 +/- 73.5
Q3	5057.1	5017.6 +/- 105.3
Total	9253.6	9171.7 +/- 128.7

TABLE III: High Luminosity Comparison

- The conclusion of these cross checks is that accurate results can be found if multiple seeds are used.
- This should as well be done in IRSYN to understand the standard deviations experienced in not only power but critical energy

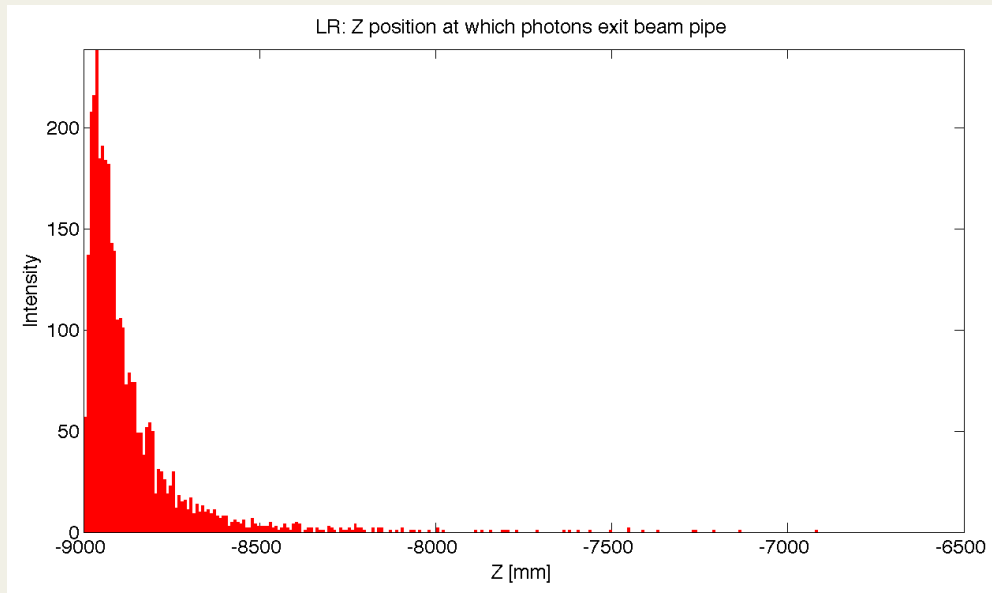


# Absorber/Backscattering



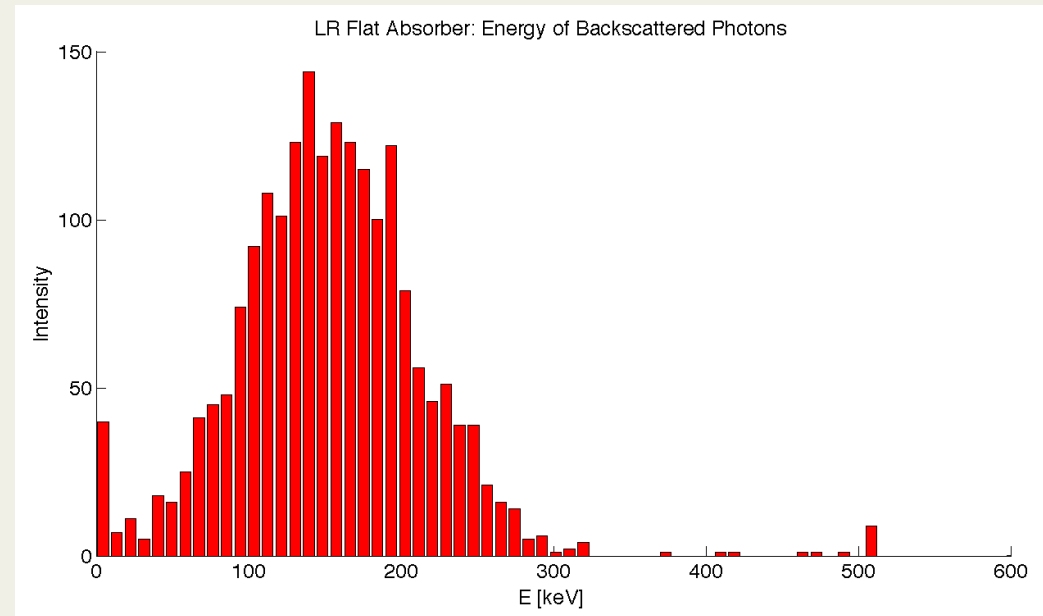
- $\gamma$  move in the negative Z direction
- D differs from simulation to simulation based on the Y extension of the SR fan.
  - $\theta$  is 40 mrad for all simulations.
- L is 3 m for the LR option and 15.5 m for the RR case.
  - R is 4 m for all simulations

# Backscattering [LR]

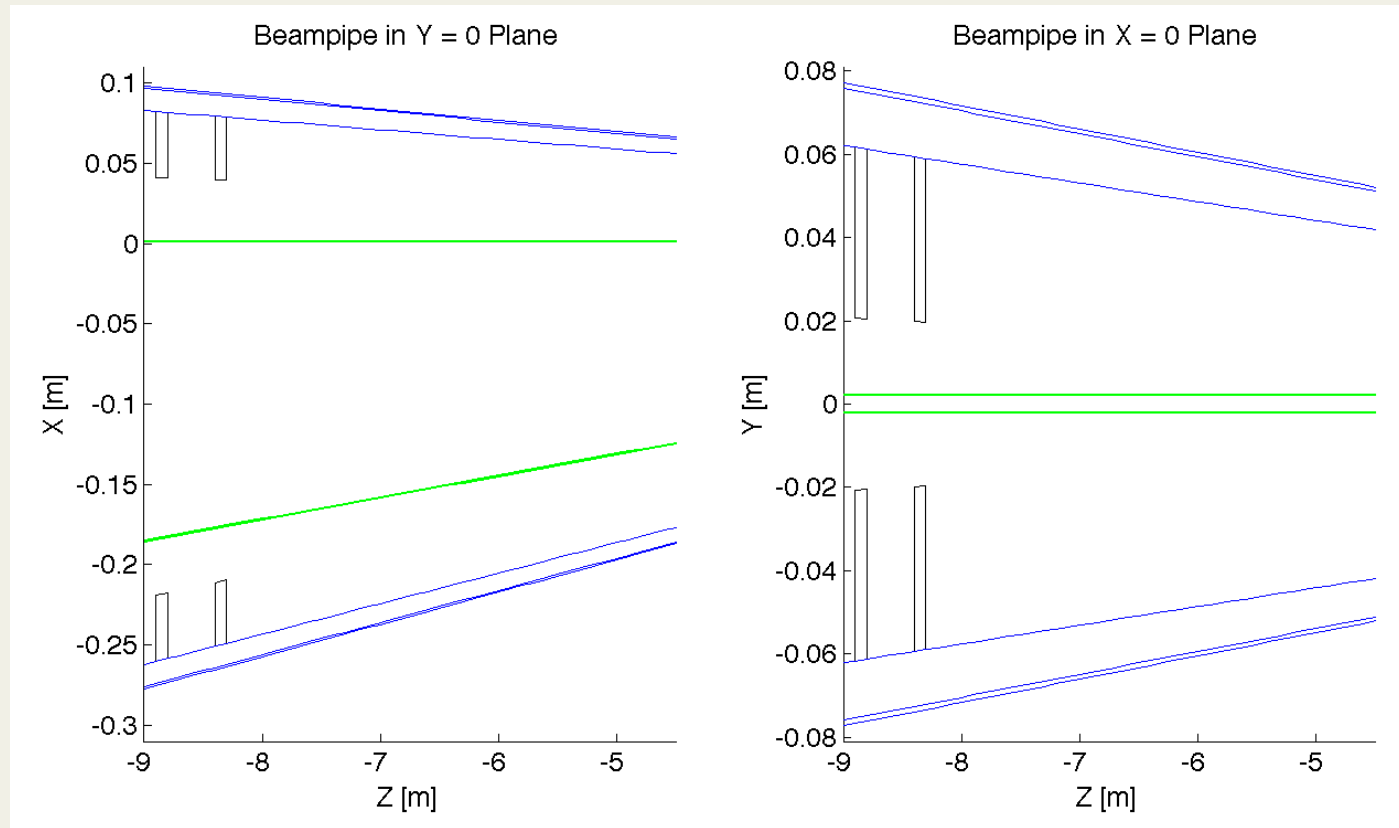


- With a generic beam pipe (as described on the next slide) this graph gives the distribution of photons hitting the beampipe in Z.
- This shows that mask placement and shielding close to the absorber can stop most of the backscattered photons.

- Backscattered photons have a normal distribution in energy in LR Case.
- For the RR cases less backscattering occurs and therefore more runs need to be made to provide accurate statistics



# Mask Placement [LR]

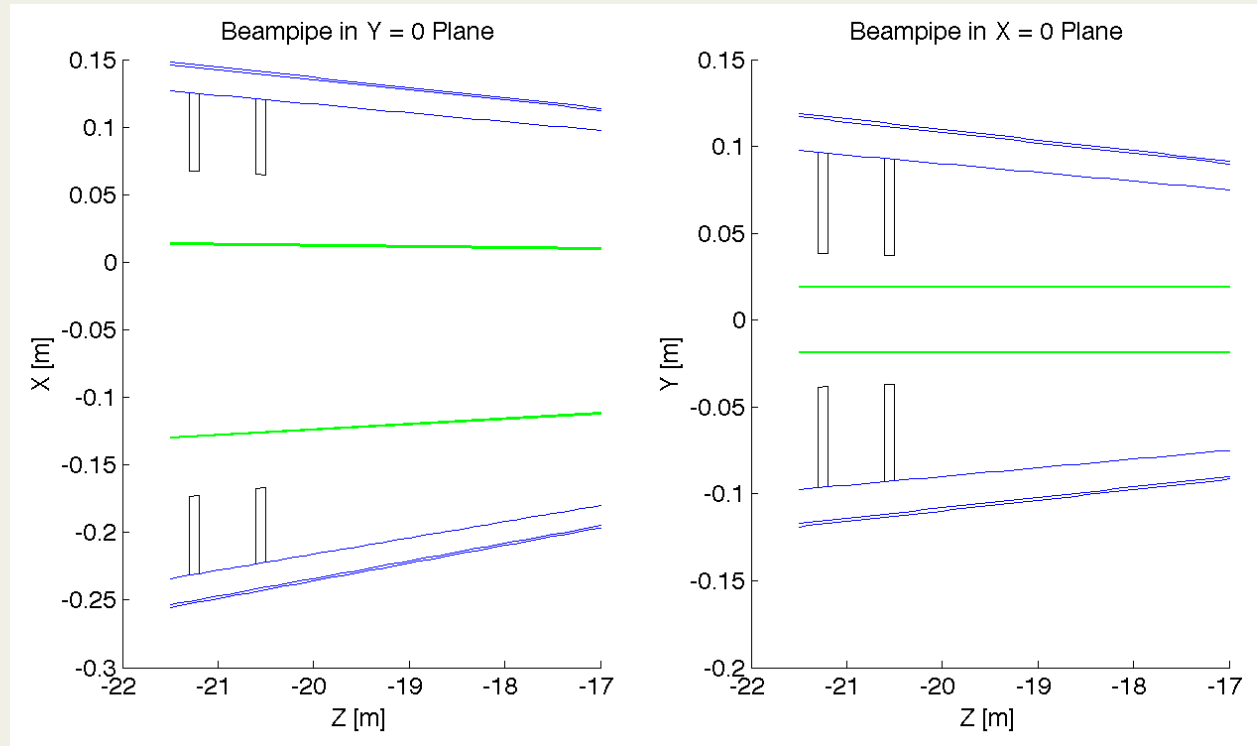


- Beampipe is circular in +X direction and elliptical in -X direction.
- Semimajor axes grow in the -Z direction.
- This has been set up with generic values.

Absorber Type	Power [W]
Flat	645.9
Cone	159.1
Flat & Mask/Shield	32.7
Cone & Mask/Shield	4.3

Table 4.5: LR: Backscattering/Mask

# Mask Placement [1 Deg]

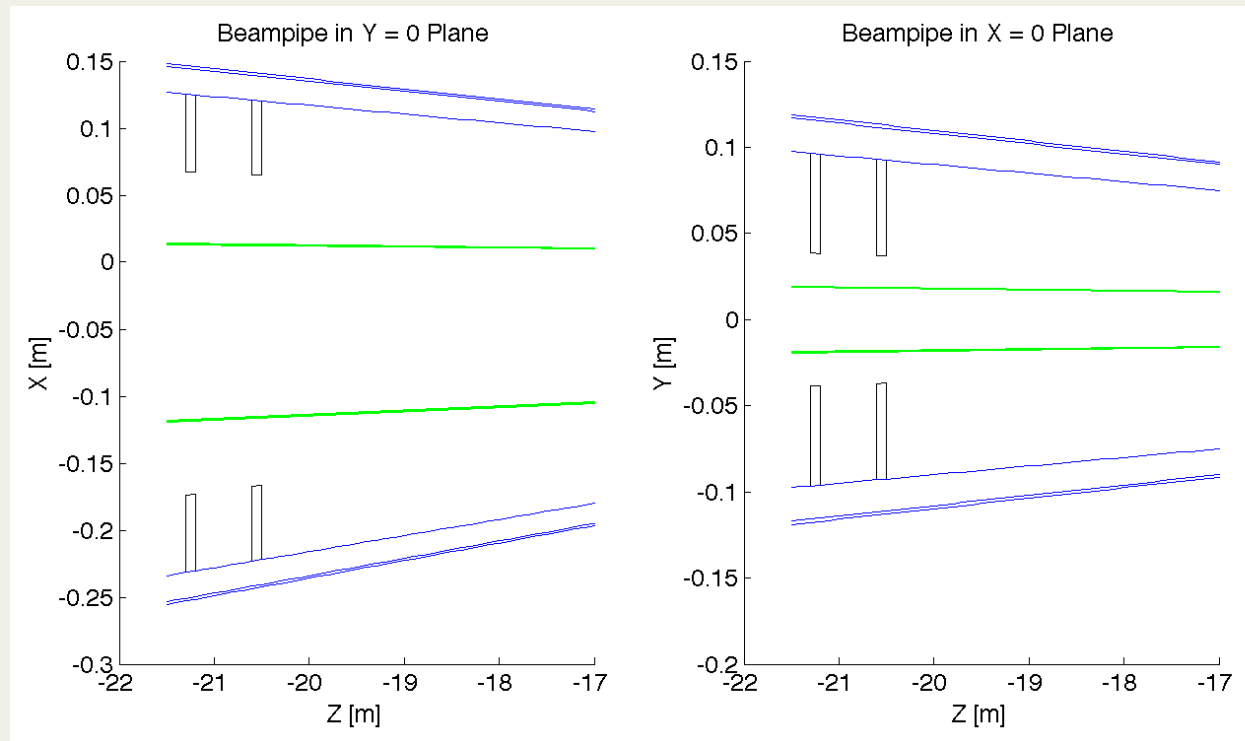


- Beampipe is circular in +X direction and elliptical in -X direction.
- Semimajor axes grow in the -Z direction.
- This has been set up with generic values.

Absorber Type	Power [W]
Flat	91.1
Cone	10
Cone & Mask/Shield	0

Table 3.10: 1 Degree: Backscattering/Mask

# Mask Placement [10 Deg]



- Beampipe is circular in +X direction and elliptical in -X direction.
- Semimajor axes grow in the -Z direction.
- This has been set up with generic values.

Absorber Type	Power [W]
Flat	22
Cone	18.5
Cone & Mask/Shield	0

Table 3.5: 10 Degree: Backscattering/Mask

# Issues

- Need tolerances for SR fan.
- Current recommendation for tolerance criterion: number density is  $O(6)$  less than peak number density in fan + 5 mm.
  - Need to know what is maximum shielding thickness possible (in radial direction) and what is maximum mask thickness possible (in z direction)
  - Need to know what is acceptable background in detector if non zero
    - Need to run everything with higher statistics